



Inventor: V. Segal; S. Ferrasse; F. Alford

Title: Physical Vapor Deposition Targets, and Methods of Fabricating Metallurgical Materials

Assignee: Honeywell International Inc.

INFORMATION DISCLOSURE STATEMENT

PURSUANT TO 37 C.F.R. §§ 1.56, 1.97 AND 1.98

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, the Examiner's attention is directed to the references listed on the attached Form PTO-1449 and copies of which are attached. No admission is made regarding whether all the submitted references are prior art.

Citation of this patent these references is respectfully requested.

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Respectfully submitted,

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